Moment canting and domain effects in antiferromagnetic DyRh₂Si₂

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(Dated: April 19, 2023)

A combined experimental and theoretical study of the layered antiferromagnetic compound DyRh₂Si₂ in the ThCr₂Si₂-type structure is presented. The heat capacity shows two transitions upon cooling, the first one at the Néel temperature $T_{\rm N} = 55$ K and a second one at $T_{\rm N2} = 12$ K. Using magnetization measurements, we study the canting process of the Dy moments upon changing the temperature and can assign $T_{\rm N2}$ to the onset of the canting of the magnetic moments towards the [100] direction away from the *c* axis. Furthermore, we found that the field dependence of the magnetization is highly anisotropic and shows a two-step process for $H \parallel 001$. We used a mean-field model to determine the crystalline electric field as well as the exchange interaction parameters. Our magnetization data together with the calculations reveal a moment orientation close to the [101] direction in the tetragonal structure at low temperatures and fields. Applying photoemission electron microscopy, we explore the (001) surface of the cleaved DyRh₂Si₂ single crystal and visualize Si- and Dy-terminated surfaces. Our results indicate that the Si-Rh-Si surface protects the deeper lying magnetically active Dy layers and is thus attractive for investigation of magnetic domains and their properties in the large family of LnT₂Si₂ materials.

I. INTRODUCTION

Ternary lanthanide-silicide compounds LnT_2Si_2 (Ln = lanthanide, T = transition metal) in the ThCr₂Si₂-type structure exhibit a large variety of physical ground states. Among them are Kondo systems [1-3], superconductors [1, 2], systems showing valence instabilities [4], systems that host exotic skyrmion phases [5] and many compounds that allow for studies of local-moment magnetism [6–9]. One member of this family, DyRh₂Si₂, came into the focus of interest again due to its recently investigated surface spin orientation [10] as well as its ultrafast magnetization dynamics [11]. According to magnetization and neutron diffraction investigations of polycrystalline samples, $DyRh_2Si_2$ (I4/mmm) shows antiferromagnetic (AFM) order below $T_N = 55 \text{ K}$. In the structure, the Dy moments form ferromagnetic (FM) layers with Dy 4f moments pointing along the c direction which are stacked antiferromagnetically along the c direction. Below $T_{N2} = (15 \pm 3) K$, a canting away from the c axis occurs amounting to a canting angle of about $(19 \pm 5)^{\circ}$ with the c axis at T = 4.2 K [12, 13]. A similar case in the LnRh₂Si₂ family of this so-called "component-separated magnetic order" was found and studied in detail in the related compound HoRh₂Si₂ [7]. From Mössbauer studies on $DyRh_2Si_2$, the transition at T_{N2} was proposed to

originate from the weak ordering of the Rh sublattice [12] which, however, is not supported by the neutron diffraction data [13]. It has to be noted that for the related compound GdRh₂Si₂, a magnetic contribution of Rh was ruled out by an XMCD study [8] explicitly. In DyRh₂Si₂, both magnetic transitions, at T_N and T_{N2} , contribute strongly to the specific heat. The heat capacity and magnetization data were compared with the simulated data including crystalline electric field (CEF) effects in an earlier study by Takano *et al.* [14].

The experimental results concerning the temperaturedependent bulk properties that are published until now [12, 13] were given with large error bars only. In order to obtain further information about the magnetic ground state of the material, we re-investigate the anisotropic behavior of DyRh₂Si₂ in single crystalline form by means of detailed magnetization, electrical transport, and heat capacity measurements. Using a mean-field model, we determined the exchange interaction parameters and the CEF parameters. We provide the $\mu_0 H - T$ phase diagrams for the magnetization process and study the material in low magnetic fields in order to identify signatures of the reorientation of antiferromagnetic domains in the magnetization data which allows for determining the direction of the canting of the moments in the structure. We examined this material with x-ray photoemission electron microscopy (XPEEM) investigating the (001) surface of the cleaved crystal and visualizing both the Dy and Si terminations. Our results lay the foundation for future XPEEM studies, particularly regarding

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the characterization of the magnetic domain structure.

II. EXPERIMENT

Single crystals of DyRh₂Si₂ were grown from indium flux using a modified Bridgman method as described in [15]. High purity starting materials Dv (99.9%, ChemPur), Rh (99.9%, Heraeus), Si (99.9999%, Wacker) and In (99.9995%, Schuckard) were weighed in a graphite inner crucible and sealed in a niobium crucible under an argon atmosphere (99.999%) subsequently. Dy, Rh, Si, and In were used in the ratio of Dy : Rh : Si : In = 1 : 2 : 2 : 49. The crystal growth was performed in a movable vertical furnace (GERO HTRV 70-250/18) using a maximum temperature of $T_{max} = 1550^{\circ}C$, a slow cooling period with a rate of $1 - 4 \,\mathrm{K/h}$ down to 1000°C followed by fast cooling to room temperature with $100 \,\mathrm{K/h}$. The crystals were separated from the flux by etching in hydrochloric acid. The here described procedure yielded platelet-shaped crystals with typical dimensions of $2 \text{ mm} \times 3 \text{ mm}$ and a thickness of $50 - 100 \mu m$.

Powder X-ray diffraction (PXRD) was performed using a Bruker D8 diffractometer (Bragg-Brentano geometry) with $\lambda = 1.5406 \text{ Å}$ CuK_{α} radiation. PXRD data of crushed single crystals were recorded and confirmed the I4/mmm tetragonal structure with the lattice parameters a = 4.0281 Å and c = 9.9251 Å which are in good agreement with literature [16]. The chemical composition of the single crystals was checked by energydispersive x-ray spectroscopy (EDX). The orientation of the platelet-shaped single crystals was determined using a Laue device with white x-rays from a tungsten anode. The comparison of the simulation with the recorded Laue patterns yielded that the largest face of the crystals is perpendicular to the [001]-direction and the large edges are [110] planes. Magnetization, heat capacity, and four-point resistivity measurements were performed down to 1.8 K using the commercial measurement options of a Quantum Design Physical Property Measurement System (PPMS). XPEEM measurements have been conducted at the SPEEM end-station at the UE49-PGM beamline of the BESSY II synchrotron radiation facility operated by the Helmholtz-Zentrum Berlin (HZB) [17]. A DyRh₂Si₂ single crystal with a size of about 2×2 mm has been cleaved at room temperature in the preparation chamber at a pressure of about $1 \cdot 10^{-10}$ mbar. After transfer into the measurement chamber, the cleaved sample was cooled to 30 K. The sample was oriented with the normal of the (001) surface to coincide with the optical axis of the microscope. In the XPEEM measurement, a $(20 \times 20) \,\mu \text{m}^2$ region of the (001) surface has been studied using a photon energy of 170 eV and linear horizontal polarization. The measurements were performed in grazing incidence with an angle of 84° between the incoming light and the surface normal. XPEEM images have been recorded for kinetic energies of the photoexcited electrons ranging from 150 eV to 170 eV in steps of 0.1 eV.



FIG. 1. Magnetic properties of DyRh₂Si₂. (a) Magnetic susceptibility at 1 T for three different field directions. An enlarged view of the low-temperature data is shown in the inset (b) for the in-plane fields. Solid lines result from the CEF model. (c) CEF-split 4f levels with each level being doubly degenerate. The ground state in the PM phase is an almost pure (99%) $M_J = 13/2$ state.



FIG. 2. (a) Field-dependence of the magnetization per Dy³⁺ at T = 1.8 K measured with $H \parallel 100$ (black), $H \parallel 110$ (blue) and $H \parallel 001$ (red). The simulated data are shown by grey, light blue, and brown lines. (b) For $H \parallel 100$ and $H \parallel 110$, a reorientation of magnetic domains and a metamagnetic transition occur at small fields. Insets (c) and (d) for $H \parallel 001, M(H)$ shows a small hysteresis around the critical fields $\mu_0 H_1^{001}$ and $\mu_0 H_2^{001}$.

III. RESULTS AND DISCUSSION

A. Mean-field model for $DyRh_2Si_2$

To simulate the magnetic properties, we used a meanfield linear-chain model with either two or four Dy sublattices. The latter was used only to model the M(H) dependencies along the [001] direction. The respective Hamiltonian has the form

$$H = \sum_{i=1}^{N} (H_{CEF,i} - \vec{\mu}_i \cdot \vec{B}) - \frac{3k_B}{J(J+1)} \sum_{i,j=1}^{N} \left[T_{ij}^a J_{x,i} \langle J_{x,j} \rangle + T_{ij}^a J_{y,i} \langle J_{y,j} \rangle + T_{ij}^c J_{z,i} \langle J_{z,j} \rangle - \frac{1}{2} \left(T_{ij}^a \langle J_{x,j} \rangle^2 + T_{ij}^a \langle J_{y,j} \rangle^2 + T_{ij}^c \langle J_{z,j} \rangle^2 \right) \right], \quad (1)$$

where N is the number of Dy sublattices, $\vec{\mu}_i$ is the magnetic moment operator, \vec{B} is the external magnetic field induction, T_{ij}^a and T_{ij}^c are the exchange interaction parameters for the in-plane and out-of-plane directions, respectively. The CEF part of the Hamiltonian is

$$H_{CEF} = B_0^2 C_0^{(2)} + B_0^4 C_0^{(4)} + B_4^4 \left(C_4^{(4)} + C_{-4}^{(4)} \right) + B_0^6 C_0^{(6)} + B_4^6 \left(C_4^{(6)} + C_{-4}^{(6)} \right), \quad (2)$$

where B_q^k are CEF parameters and $C_q^{(k)}$ are spherical tensor operators. We used LSJ coupling scheme and the basis was limited to the $|M_J\rangle$ states of the ground $|LSJ\rangle$ state of the $4f^9$ subshell.

The Hamiltonian 1 was diagonalized self-consistently using an iterative scheme. We started from several intuitively selected magnetic structures and arrived at a few magnetic configurations from which the one with minimal energy was chosen. The exchange interaction parameters $T_{ij}^{a(c)}$ were fitted together with the CEF parameters B_q^k to obtain best agreement between the theoretical and experimental dependencies $\chi(T)$ at 1 T (Fig. 1(a)) and M(H)at 1.8 K (Fig. 2) for the [100], [110] and [001] directions. Due to symmetry, we have $T_{12}^{a(c)} = T_{14}^{a(c)}$. Additionally, the parameter T_{13}^a was kept equal to T_{13}^c since it cannot be determined from our data due to its linear correlation with T_{11}^a .

B_{0}^{2}	B_0^4	B_4^4	B_{0}^{6}	B_{4}^{6}	Plane	Source
36.86	-39.45	44.48	0.837	11.98	(100)	this work
31.76	-37.85				undefined	Ref. [18]
36.65	-50.07	6.959			(100)	Ref. [14]

TABLE I. CEF parameters B_q^k in meV and corresponding crystallographic plane, in which the moments deviate from the [001] direction.

T_{11}^{a}	$T_{12}^a = T_{14}^a$	$T_{13}^a = T_{13}^c$	T_{11}^{c}	$T_{12}^c = T_{14}^c$
$24.907~\mathrm{K}$	$-9.194 { m K}$	$-5.5~\mathrm{K}$	$23.049~{\rm K}$	$-8.245 {\rm K}$

TABLE II. Optimized exchange interaction parameters of the mean-field model.

The obtained CEF parameters are given in Tab. I. It should be noted that in the previous studies [14, 18] the

parameters B_0^6 and B_4^6 were not estimated. The B_0^2 and B_4^0 parameters show a reasonable agreement with our values. The exchange interaction parameters given in Tab. II were found to be slightly different for the in-plane (a) and out-of-plane (c) directions. Without this anisotropy, the simulated magnetic properties would show significantly worse agreement with the experimental data. It should be noted that although our model provides a good fit for the susceptibility in Fig. 1, one can see some discrepancies close to T_N in the [001] direction and close to T_{N2} in the [110] direction. This is probably related to the neglect of spin fluctuations.

B. Magnetization

The magnetic properties of $DyRh_2Si_2$ arise from the local moment magnetism of the Dy^{3+} ion with a spin momentum of S = 5/2 and an orbital angular momentum L = 5 resulting in a total angular momentum of J = 15/2. Polycrystalline samples of the system showed AFM order below $T_N = 55 \text{ K}$ with moments along [001] [12, 13]. A second transition was found at ≈ 15 K which was assigned to the onset of a canting process of the magnetic moments away from the [001] direction. Our single crystals allow for a detailed study of the anisotropic magnetization of DyRh₂Si₂. We determined the temperature and field-dependent magnetic susceptibility with field along the three crystallographic main symmetry directions [001], [100] and [110] in order to obtain further information about the magnetic ground state of the material, especially about the orientation of the magnetic moments in the bulk.

1. Temperature dependence of the susceptibility

In Fig. 3, the comparison of the anisotropic temperature dependent susceptibility, $\chi_{mol}(T)$, measured at 0.01 T is presented for $H \parallel 100, H \parallel 110$ and $H \parallel 001$. $\chi_{\rm mol}(T)$ for $H \parallel 001$, shows that the system enters the antiferromagnetic phase below $T_{\rm N} = 55 \, {\rm K}$. In contrast, when the field is applied along the [100] or [110] directions (inset of Fig. 3), $\chi_{\rm mol}(T)$ shows only a small kink at $T_{\rm N}$ but a pronounced anomaly followed by a strong decrease below $T_{N2} = 12 \text{ K}$. In our setup, we measure the projection of the Dy moment M onto the direction of the applied field $H, \mathbf{M} \cdot \mathbf{H}/H$ and the almost complete absence of a kink at $T_{\rm N}$ for $H \perp 001$ is consistent with moment alignment along c at the Neel temperature for which $\mathbf{M} \cdot \mathbf{H}/H = 0$. Below T_{N2} , the moments tilt away from the c axis leading to a non-zero projection for $H \perp 001$ and a strong change of the susceptibility. For different higher fields applied along the three main symmetry directions, $\chi_{\rm mol}(T)$ is shown in the Supporting Information Figs. S1(a), S2(a) and S3(a).

Following the common practice, we determined the Weiss temperature Θ_W and the effective magnetic mo-



FIG. 3. Temperature-dependent susceptibility for the three main symmetry directions with $\mu_0 H = 0.01$ T. In the inset, a schematic drawing of the experimental setup is shown for $H \perp 001$ of the sample s.



FIG. 4. Inverse susceptibility measured at $\mu_0 H = 1$ T. Solid gray and black lines indicate the region of the Curie-Weiss fit above 150 K.

ment μ_{eff} according to

$$\chi_{\rm mol}^{-1}(T) = -\frac{\Theta_W}{C_{\rm mol}} + \frac{1}{C_{\rm mol}}T \tag{3}$$

and $\mu_{\text{eff}} = \sqrt{3k_{\text{B}}C_{\text{mol}}/\mu_0 N_A}$ with the Boltzmann constant k_{B} , the molar Curie constant C_{mol} , the vacuum permeability μ_0 and the Avogadro number N_A from the inverse susceptibility, Fig. 4, measured with $\mu_0 H = 1$ T. We obtained negative Weiss temperatures $\Theta_{\text{W}}^{100} = -29.4$ K, $\Theta_{\text{W}}^{110} = -30.2$ K for in-plane fields and a positive Weiss temperature, $\Theta_{\text{W}}^{001} = 36.5$ K, for $H \parallel 001$. The main reason for the different signs of the Weiss temperatures is related to the CEF that leads to the strong



FIG. 5. $\mu_0 H - T$ phase diagram for $H \parallel 001$. In DyRh₂Si₂, upon increasing the field, the magnetic configuration changes in two steps from + - + - (AFM I) to + + + - (AFM II) before reaching the + + + + field polarized (FP) state. Upon increasing the temperature, the paramagnetic (PM) state is reached. Red circles mark transitions extracted from M(H)data and triangles were extracted from $\chi_{mol}(T)$. Brown diamonds and stars show the result of the simulation of M(H)and $\chi_{mol}(T)$.

anisotropy of the susceptibility. The effective magnetic moment $\mu_{\rm eff}^{100,110}=10.8\,\mu_{\rm B}$ and $\mu_{\rm eff}^{001}=11.1\,\mu_{\rm B}$ is slightly anisotropic and agrees well with the calculated value $\mu_{\rm eff}^{\rm calc}=g_J\sqrt{J(J+1)}\,\mu_{\rm B}=10.65\,\mu_{\rm B}$ which is the highest among all ${\rm Ln}^{3+}$ ions.

2. Field-dependence of the magnetization

The field-dependence of the magnetization at T =1.8K shows anisotropic behavior and is presented in Fig. 2 (a). For $H \parallel 001$ (red curve), we observe a step-like behavior of the magnetization due to changes of the magnetic configuration at $\mu_0 H_1^{001} = 4.0 \text{ T}$ and at $\mu_0 H_2^{001} = 8.2 \,\mathrm{T}$. At both transitions, a small hysteresis in the magnetization occurs Fig. 2 (c) and (d). With $M = 9.1 \,\mu_{\rm B} / {\rm Dy}^{3+}$ at the highest here investigated field, the magnetization is slightly lower than the calculated saturation magnetization of $M_{\rm sat}^{\rm calc} = g_J J = 10 \mu_{\rm B} / {\rm Dy}^{3+}$ with g = 4/3 being the Landé g factor. The reason for this is the deviation of moments from the c axis due to the CEF. In our model, the field of 36 T is required to align all moments along the c direction at 1.8 K. At $\mu_0 H_1^{001} = 4.0 \,\mathrm{T}$ the magnetic configuration changes from + - + - (AFM I) to + + + - (AFM II) and at $\mu_0 H_2^{001} = 8.2 \,\mathrm{T}$ to the field-polarized + + + + (FP) configuration. Our mean-field simulations indicate that the reason for such a two-step process is related to the negative sign of the T_{13}^c parameter. Similarly to the case of TbRh_2Si_2 [19], AFM coupling between the neighbor Dy



FIG. 6. Comparison of the low-field behavior of $\mathbf{M} \cdot \mathbf{H}/H^2$ vs. $(\mu_0 H)^2$ at T = 1.8 K for increasing H along the three main symmetry directions.

sublattices (layers) 1 and 2 is in conflict with the AFM coupling between the sublattices 1 and 3. As a result of such frustration, the moments in the two sublattices flip at different values of H. In the case of positive T_{13}^c there would be only one step. Next, we extracted the reorientation fields at different temperatures from Figs. S1a and S4a in the Supporting Information to draw the $\mu_0 H - T$ phase diagram for $H \parallel 001$, as shown in Fig. 5. Our experimental diagram is qualitatively similar to that of TbRh₂Si₂ [19]. However, our mean-field model gives better agreement with experiment than the 1D Ising chain model used in Ref. [19].

For $H \parallel 100$ (black curve in Figs. 2 and 6) and $H \parallel 110$ (blue curve), we observe changes of the slope at $\mu_0 H_1^{100} = 0.5 \text{ T}$, $\mu_0 H_2^{100} = 5.1 \text{ T}$, $\mu_0 H_1^{110} = 1.1 \text{ T}$ and at $\mu_0 H_2^{110} = 5.3 \text{ T}$ as shown in Fig. 2 (a,b) and Fig. 6. For in-plane fields, the magnetization at 8 T is much lower than the calculated saturation value.

3. Low-field behavior of the magnetization

By comparing the low-field behavior of the magnetization per Dy³⁺ for the three main symmetry directions, presented as $M/\mu_0 H$ versus $(\mu_0 H)^2$ in Fig. 6, we find an anisotropy not only between the in and out-of-plane data but also between the in-plane data (black curve $H \parallel 100$ and blue curve $H \parallel 110$). A closer look on the low-field data for $H \parallel 100$, shown in Fig. 7, most clearly visible when displayed as $M/\mu_0 H$ versus $\mu_0 H$, indicates that below 10 K strong changes of $M/\mu_0 H$ appear at fields below 0.5 T. The curves recorded at 1.8 K and 5 K show a small field-induced hysteresis. We deduce that this change of the slope for $H \parallel 100$ at low fields is connected to a



FIG. 7. $\mathbf{M} \cdot \mathbf{H}/H^2$ versus $\mu_0 H$ for $H \parallel 100$. Below 10 K, a strong change of slope and a small AFM hysteresis occur which indicates the reorientation of magnetic domains.

magnetic reorientation below $\mu_0 H_1^{100} = 0.5 \,\mathrm{T}$. A similar non-linear behavior was found in $GdRh_2Si_2$ (H || 110) and was assigned to the reorientation of antiferromagnetic domains [8]. Note that our mean-field model does not describe the reorientation of domains. In contrast, for $H \parallel 110$ (blue curve), $M \propto (\mu_0 H)^2$ and a metamagnetic spin-flop transition occurs below $\mu_0 H_1^{110} = 1.1 \,\mathrm{T}$ (Figs. 6 and S6) that is well-described by our model. For $H \parallel 001$ (red curve) in Fig. 2 (a), the susceptibility is almost zero below $\mu_0 H_1^{001}$ and together with the domain-reorientation behavior observed for $H \parallel 100$ below $\mu_0 H_1^{100} = 0.5 \,\mathrm{T}$, this indicates a moment tilting towards the [100] direction which is consistent with the result of the calculations given in Tab. I. Our calculations show that the moments are oriented along [001] between $T_{\rm N}$ and $T_{\rm N2}$ and become canted in the (100) or (010) plane at lower temperatures and zero external fields with the maximal canting angle of 24.3° from the *c* direction. The field dependence of the material was experimentally studied with $H \parallel 100$, for different higher temperatures and is compared to the simulation in Fig. S5 in the Supporting Information.

For $H \parallel 110$, $\mu_0 H < 1.3 \text{ T}$ and low temperatures, Fig. S6, M/H shows a linear $(\mu_0 H)^2$ dependence as the signature of a spin-flop transition [8]. In zero field and below T_{N2} the moments are oriented by the CEF in the (100) (or (010)) plane. Upon the increase of the field, they tend to be orthogonal to the field. This results in the gradual rotation of the moments towards the (110) plane. From the field- and temperature-dependent data Figs. S3(a), S6, and S7(a) (Supporting Information), we extracted the transition temperatures in the field along [110] to draw the $\mu_0 H - T$ phase diagram, Fig. 8, in which the region of the spin-flop (SF) phase is marked.



FIG. 8. $\mu_0 H - T$ phase diagram for $H \parallel 110$. Circles mark transitions extracted from M(H) data and triangles were extracted from $\chi_{\text{mol}}(T)$. Diamonds show the results of the simulations.



C. Heat capacity and entropy

The heat capacity, Fig. 9, was measured between 1.8 K and 200 K. It shows a λ -type anomaly at $T_{\rm N} = 55$ K and a further transition at $T_{\rm N2} = 12 \,\rm K$. The recorded data agree well with those published by Takano *et al.* [14]. The phonon contribution was subtracted using the nonmagnetic reference data of LuRh₂Si₂ which were taken from [20]. We note that below 5 K the Lu reference exhibits a larger heat capacity than $DyRh_2Si_2$ which leads to unphysically negative values of the magnetic specific heat and of the entropy at low temperatures. Possible reasons might be a higher electronic heat capacity or a slightly different phonon spectrum in LuRh₂Si₂ due to the mass differences of Dy and Lu. Due to the lowlying transition at $T_{\rm N2}$ and magnonic degrees of freedom, C/T versus T^2 shows a non-linear behavior that hinders the determination of the Sommerfeld coefficient γ from the low-temperature data. The magnetic entropy, Fig. 10, of DyRh₂Si₂ reaches almost $S^{4f} = R \ln 8$ at T_N which is much smaller than the expected entropy $S^{4f}(Dy^{3+}) = R \ln(2J+1) = R \ln 16$ for the free Dy^{3+} ion, this indicates that the overall splitting of the CEF levels is larger than T_N which is consistent with our calculated CEF scheme. From Fig. 1(c) it can be seen, that below $T_{\rm N}\,=\,55\,{\rm K}\,\approx\,4.7\,{\rm meV}$ the lowest four doubly degenerate CEF energy levels have a significantly greater population than the higher levels. This is in agreement with the entropy being close to $S^{4f} = R \ln 8$ for the 4 CEF doublets.

FIG. 9. (a) Heat capacity of DyRh₂Si₂ and LuRh₂Si₂ [20]. (b) C/T versus T² of DyRh₂Si₂ does not show linear behavior below 10 K which hinders the determination of the Sommerfeld coefficient and hints at a magnon contribution to the heat capacity below T_{N2}. (c) The magnetic part of the heat capacity, C^{4f} , was determined by using the non-magnetic reference LuRh₂Si₂ (gray symbols in (b)).



FIG. 10. Magnetic entropy, S^{4f} , of $DyRh_2Si_2$. The experimental data were obtained from C^{4f} after subtracting the data of the non-magnetic reference (gray solid line). The simulation is shown in black.



FIG. 11. Normalized resistivity of DyRh₂Si₂

D. Electrical resistivity

The normalized electrical resistivity, Fig. 11, exhibits linear behavior for both current directions between 300 K and T_N . At T_N , upon entering the antiferromagnetic phase the behavior is different for both current directions $j \perp c$ and $j \parallel c$. As shown in the inset of Fig. 11, below T_N the resistivity drops for $j \perp c$ while it shows a slight increase for $j \parallel c$ indicating a decrease of the number of states near the Fermi level caused by a sudden slight enlargement of the unit cell in c-direction. It has to be noted that for the sister compound GdRh₂Si₂ a similar but even stronger effect on the temperature dependence of the resistivity can be observed [21]. There, this increase of the resistivity for $j \parallel c$ occurs below $T_{\rm N}$ where the c parameter of the magnetic unit cell becomes twice as large as that of the structural cell which reduces the number of states that contribute to the conductivity. The residual resistivity ratio of $RR_{2K} = 10.4$ for $j \perp c$ is slightly larger than $\operatorname{RR}_{2 \mathrm{K}} = 7.4$ determined for $j \parallel c$.

E. XPEEM

We now discuss the spectromicroscopic investigation of the cleaved (001) surface of AFM-ordered DyRh₂Si₂. The results are summarized in Fig. 12. The ultimate XPEEM image shown in Fig. 12(a) results from integration over the given kinetic energies. As we can see from Fig. 12(a), the XPEEM image taken with a photon energy of 170 eV for kinetic energies ranging from 150 eV to 170 eV, reveals large and homogeneous, bright- and dark-shaded areas. At the given photon energy, the crosssection for the photoexcitation of valence electrons is considerably smaller than for the excitation of electrons from the Dy 4f shell. From ARPES studies of DyRh₂Si₂ and related LnRh₂Si₂ compounds, it is known, that cleaving of the sample results in two different terminations of the (001) surface: Dy or Si termination. Because of the high surface sensitivity at the given photon energy due to the small escape depth of the photoelectrons, which decays exponentially with increasing distance from the surface, we may assume that the more intense, bright areas in the XPEEM image reflect Dy-terminated regions. For Si termination, the first Dv laver lies below a Si-Rh-Si triple-layer surface block which results in a reduced 4fphotoemission (PE) signal in comparison to Dy at the surface. The Dy 4f photoemission spectra, Fig. 12(b), were obtained from intensity integration over the two designated regions of interest in the individual XPEEM images recorded in dependence on the kinetic energy. In Fig. 12(b), we show Dy 4f PE spectra obtained from representative regions of the bright and dark-shaded areas that are marked in Fig. 12(a) by red- and cyan-colored squares, respectively. In the 4f PE spectra, we observe two different line shapes characteristic of the bright and dark areas. As we demonstrated previously, the change of the crystal electric field at the Dy surface leads to a strong reorientation of the 4f moments, which are found to gain a large component within the surface plane, while they have an out-of-plane orientation in the bulk [10]. The orientation of the 4f moments can be derived from a comparison of the line shapes of the Dy 4f PE spectra with calculated spectra for the individual M_J final states [22]. Since the line shape of a 4f PE spectrum depends also on the experimental geometry [10, 22], we calculated the Dy 4f PE spectra for the geometry of the given XPEEM experiment. The computational results are given in Fig. 12(c). Comparing the experimental results in Fig. 12(b) with the computed Dy 4f spectra, we find the best agreement between the two spectra highlighted in cyan color, where the calculated one corresponds to $M_J = 11/2$. This indicates that the 4f moments are mostly oriented out of the (001) plane which is characteristic of the bulk. In accordance with our initial assumption, we conclude that the dark-shaded areas in the XPEEM image represent the silicide surface of the DyRh₂Si₂ crystal, where the first Dy atomic layer is hidden below the Si-Rh-Si surface block in a bulk-like environment. That the best-fitting calculated spectrum is not the one for the maximum value $M_J = 15/2$ implies, however, a canting of the 4f moments away from the c axis. In contrast, the red-colored spectrum in Fig. 12(b) belonging to the bright area of the XPEEM image does not fit any of the calculated spectra. This indicates that the Dy surface, which is much more reactive than the silicide surface, has already undergone essential modifications due to possible contamination. Notice, that the sample has been cleaved at room temperature and was subsequently transported from the preparational to the analytical chamber. Hence, contamination of the highly reactive rare-earth-terminated surface of the crystal must be expected. The overall instructive results obtained from our XPEEM experiment on the (001) surface of



FIG. 12. Spectromicroscopic insight into the surface terminations of $DyRh_2Si_2$. (a) Representative XPEEM image showing a $(20 \times 20) \mu m^2$ area of the (001) surface from a cleaved $DyRh_2Si_2$ single crystal at a temperature of 30 K using a photon energy of 170 eV. The image results from integration over kinetic energies of the photoelectrons ranging from 150 eV to 170 eV. Bright and dark regions reflect surface areas with Dy and Si terminations, respectively. (b) Dy 4f photoemission spectra derived from the bright and dark areas in the XPEEM image that are highlighted by red- and cyan-colored squares, respectively. (c) Calculated M_J -dependent Dy 4f spectra for the geometry of the XPEEM measurements. The calculated spectrum that shows the best agreement with the experimental one taken from the Si surface is highlighted in cyan.

DyRh₂Si₂ can be considered as a feasibility check for upcoming measurements. They allow us to plan further studies addressing the investigation of magnetic domains in the large family of LnT₂Si₂ materials. Based on our findings for DyRh₂Si₂, in future experiments, the focus should be laid on the chemically less active silicide surfaces. Our previously published results indicate that systems like AFM GdRh₂Si₂ may reveal surface and bulk magnetic domains below the Si-Rh-Si surface which have their own characteristic properties [23]. Our results for DyRh₂Si₂ suggest that the silicide block essentially protects the deeper-lying magnetically active lanthanide layers from experimental environments and prevents them from quick contamination and degradation in comparison to the Dy-terminated surface. This gives good hope to believe that the silicide surfaces of LnT₂Si₂ materials serve as a platform for the investigation of the physical properties and temperature scales of FM and AFM domains in such curious 4f-based materials by means of XMCD/XMLD PEEM measurements.

IV. CONCLUSIONS

We determined the exchange interaction parameters of a mean-field linear-chain model by fitting those together with the CEF parameters to experimental magnetization data of DyRh₂Si₂ ($\chi(T)$ at 1 T and M(H) at 1.8 K). The simulation of the field and the temperaturedependent susceptibility data as well as the heat capacity data shows excellent agreement with experimental data and reveals two magnetic transitions at $T_{\rm N} = 55$ K and at $T_{\rm N2} = 12$ K. We studied the magnetization behavior in field and found for $H \parallel 001$ a two-step magnetization process, similar to that in $HoRh_2Si_2$ [24] and in HoIr₂Si₂ [9]. For $H \parallel 100$, we observe the signatures of the reorientation of magnetic domains and spinflop behavior with $H \parallel 110$. The low-field M/H data show that the moments are aligned closer to the (100)than to the (110) plane which is consistent with the result of our simulations yielding a tilting of the moments towards [100] away from the c direction at low T. Finally, using XPEEM we visualized and investigated the Si- and Dy-terminated surfaces of the cleaved crystal. Although the Dy surface contaminates quickly, the silicide surface is quite robust and protects the underlying Dy layer from experimental environments. Our results suggest that the Si-terminated surface is attractive for temperature-dependent studies of magnetic domains and their properties by means of XPEEM for the huge family of strongly correlated LnT₂Si₂ materials.

V. ACKNOWLEDGMENTS

We thank K.-D. Luther and T. Förster for technical support. We acknowledge funding by the Deutsche Forschungsgemeinschaft (DFG, German Research Foundation) via the SFB/TRR 288 (422213477, project A03) and via the SFB1143 (47310070, project C04). This work was supported by the Saint Petersburg State University (Grant No. 94031444). D.Yu.U. acknowledges support by the Ministry of Science and Higher Education of the Russian Federation [Grant No. 075-15-2020-797 (13.1902.21.0024)]. We acknowledge the Helmholtz-Zentrum Berlin für Materialien und Energie for beamtime at the SPEEM instrument (UE49-PGM) at the BESSY II electron storage ring [17]. We would like to

thank Florian Kronast and Alevtina Smekhova for exceptional scientific support during the experiment.

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